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XP-002282333

AN - 1995-110113 [35]

AP - JP19930224903 19930723; [Previous Publ. JP7032531]

CPY - KUWA-I

DC - A28 A92 P73

FS - CPI;GMPI

IC - B32B7/02; B32B9/00; B32B27/00; B32B27/06; C08J7/00; C08J7/04

MC - A06-A00E A12-P01B

PA - (KUWA-I) KUWAHARA Y

PN - JP3465311B2 B2 20031110 DW200377 B32B9/00 005pp

- JP7032531 A 19950203 DW199515 B32B9/00 005pp

PR - JP19930224903 19930723

XA - C1995-050211

XIC - B32B-007/02; B32B-009/00; B32B-027/00; B32B-027/06; C08J-007/00; C08J-007/04

XP - N1995-086823

- AB J07032531 The plastic material consists of plastic material pref long moulding, 0.005-0.05 mum thick layer of the polymer with 2.0-2.3 of refraction index and 0.03-0.2mum thick of the top layer of silicon oxide with 1.4-1.6 of refraction index. The first layer is prepared by polymerising silicon cpd comprising 15% or more of Si, 20% or more of C and the rest of oxygen under the pressure from 3 multiplied by 10-3 to 3 multiplied by 10-2torr by plasma CVD method. The second layer contains 60% or more of silicon oxide with general formula SiOx (x=1.5-2.0). Also claimed is the preparation.
 - USE For wrapping materials such as films, cups, bottles.
 - ADVANTAGE Very thin membrane reduces water vapour permeation under 0.5 g/ m2 day, and is reclaimed.

- (Dwg.0/0)

IW - GAS INSULATE PLASTICS MATERIAL THIN TRANSPARENT MEMBRANE SILICON COMPOUND PLASTIC MATERIAL SILICA TOP LAYER SPECIFIED REFRACT INDEX IKW - GAS INSULATE PLASTICS MATERIAL THIN TRANSPARENT MEMBRANE SILICON COMPOUND PLASTIC MATERIAL SILICA TOP LAYER SPECIFIED REFRACT INDEX

NC - 001

OPD - 1993-07-23

ORD - 1995-02-03

PAW - (KUWA-I) KUWAHARA Y

- TI Gas insulating plastics material with thin transparent membrane of silicon cpd has plastic material and silica top layer of specified refraction index
- A01 [001] 017; S9999 S1581; P0884 P0839 H0293 F41 D01 D11 D10 D19 D18 D31 D50 D63 D90 E21 E00; S9999 S1434; S9999 S1285-R;
 - [002] 017; ND01; Q9999 Q8560 Q8366; Q9999 Q8435 Q8399 Q8366; Q9999 Q8399-R Q8366; Q9999 Q8366-R; N9999 N7158 N7034 N7023; K9698 K9676; N9999 N6906; ND07;
 - [003] 017; B9999 B5163 B5152 B4740; B9999 B5243-R B4740; N9999 N7090 N7034 N7023; B9999 B5447 B5414 B5403 B5276;
- A02 [001] 017; G2346 G2335 D00 D09 O- 6A; G2302 G2299 G2266 D01 Si 4A D11 D10 D50 D86 F86 F81; R00326 G0044 G0033 G0022 D01 D02 D12 D10 D51 D53 D58 D82; P1445-R F81 Si 4A; L9999 L2619 L2506; K9665; L9999 L2528 L2506; H0033 H0011; P0033; P1423 Si 4A; H0260; S0009 S1285-R; L9999 L2766; P1150;

NSDOCID: <XP_____2282333A__I

- [002] 017; ND01; Q9999 Q8560 Q8366; Q9999 Q8435 Q8399 Q8366; Q9999 Q8399-R Q8366; Q9999 Q8366-R; N9999 N7158 N7034 N7023; K9698 K9676; N9999 N6906; ND07;

- [003] 017; B9999 B5243-R B4740; B9999 B4444 B4240; Q9999 Q8060; B9999 B4875 B4853 B4740; K9610 K9483; N9999 N7090 N7034 N7023; N9999 N7136 N7034 N7023; B9999 B5436 B5414 B5403 B5276; B9999

B4397 B4240; K9847-R K9790;

BNSDOCID: <XP_____2282333A__1_>